

ABSTRACT

A method of patterning a functional material (150) onto a substrate (100) comprises
5 the steps of (a) applying a layer of protective material (130), soluble in a solvent in
which the functional material is insoluble, to at least one major surface of said
substrate; (b) removing areas of said layer (130) to gain access to the substrate in
well-defined regions; (c) depositing the functional material (150) at least onto the
substrate in the well-defined regions; and (d) removing the remaining layer of
10 protective material from the substrate by dissolution in said solvent.